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U.S. **UTILITY** Patent Application

O.O. OTILITI I atent Applic	auon	
O.I.P.E.	PATENT DATE	
SCANNED KC4 Q.A. LR		

A	PPLICATION NO. 09/811419	CONT/PRIOR F	CLASS 355 430	SUBCLASS 30	ART UNIT / 8	EXAMINER H.N	grijen
APPLICANTS	Masaya Ogu Eiichi Mur Nobuaki Og	rakami	•	· , ,			V
TITLE	Exposure a and plant	apparatus therefor	, method	of manufa		semiconductor	devices

ISSUING CLASSIFICATION								
ORIGINA	ORIGINAL CROSS REFERENCE(S)							
CLASS	SUBCLASS	CLASS SUBCLASS (ONE SUBCLASS PER BLOCK)						
INTERNATIONAL	L CLASSIFICATION							
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TERMINAL	•	DRAWINGS		CLAIMS ALLOWED		
L.J DISCLAIMER	Sheets Drwg.	Figs. Drwg.	Print Fig.	Total Claims	Print Claim for O.G.	
☐ The term of this patent subsequent to (date)	•		<u>,</u> .	NOTICE OF ALLOWANCE MAIL		
has been disclaimed.	(Assistant Examiner)		(Date)			
The term of this patent shall not extend beyond the expiration date		÷				
of U.S Patent. No.				ISSUE FEE		
				Amount Due	Date Paid	
	(Primary Examiner) (Date)				12	
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this patent have been disclaimed.	(Legal Instrume	ents Examiner)	(Date)			
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